



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#442  
9-20-0  
Harrison

Application Serial No. .... RECEIVED ..... 09/602,395  
Filing Date ..... SEP 19 2001 ..... June 22, 2000  
Inventor ..... Moore, J. ....  
Assignee ..... TECHNOLOGY CENTER 2800 Micron Technology, Inc.  
Group Art Unit ..... 2813 .....  
Examiner ..... Nguyen, T. ....  
Attorney's Docket No. ..... MI22-1384  
Title: (As Amended) Methods of Forming Oxide Regions Over Semiconductor  
Substrates

RESPONSE TO AUGUST 14, 2001 OFFICE ACTION

To: BOX NON-FEE AMENDMENT  
Assistant Commissioner for Patents  
Washington, D.C. 20231

From: Jennifer J. Taylor, Ph.D. (Tel. 509-624-4276; Fax 509-838-3424)  
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AMENDMENTS

In the Specification

Please replace the Title with the following new Title:

--METHODS OF FORMING OXIDE REGIONS OVER SEMICONDUCTOR  
SUBSTRATES--

In the Claims

Cancel claims 17-28.